

ABSTRACT OF THE DISCLOSURE

A method of producing a substrate with marks is provided in which a method of forming marks nonparallel to the direction of generation of a factor that hinders reading and a method of forming marks while offsetting marking positions in a direction perpendicular to the direction of generation of the factor of hindrance are combined to enable the consecutive marks to have different portions subjected to hindrance to reading, and the results of reading of the marks are compared with each other to perform processing for complementation of the portion subjected to the hindrance.